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*It is here by certified that the paper ID : IJRASET53444, entitled  
Corrosion Inhibition of Copper Metal by Ethanolic Extract of Tinospora Cordifolia Plant in Sulfuric and  
Hydrochloric Acids of varying Strength (0.5 N to 3N) using Additives*

*by  
Vineeta Mandawara*

*after review is found suitable and has been published in  
Volume 11, Issue VI, June 2023  
in*

*International Journal for Research in Applied Science &  
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